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| APPLICATION<br>NUMBER | FILING or<br>371(c) DATE | GRP ART<br>UNIT | FIL FEE REC'D | ATTY. DOCKET NO | TOT CLAIMS | IND CLAIMS |
|-----------------------|--------------------------|-----------------|---------------|-----------------|------------|------------|
| 10/585,707            | 07/10/2006               | 2812            | 1700          | KANEKO.014AUS   | 24         | 6          |

CONFIRMATION NO. 4346

MURAMATSU & ASSOCIATES  
114 Pacifica  
Suite 310  
Irvine, CA 92618

FILING RECEIPT



Date Mailed: 08/14/2008

Receipt is acknowledged of this non-provisional patent application. The application will be taken up for examination in due course. Applicant will be notified as to the results of the examination. Any correspondence concerning the application must include the following identification information: the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. **If an error is noted on this Filing Receipt, please submit a written request for a Filing Receipt Correction. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections**

**Applicant(s)**

Minoru Umemoto, Aichi, JAPAN;  
Yoshikazu Todaka, Aichi, JAPAN;  
Tadashi Suzuki, Shizuoka, JAPAN;  
Toshiichi Ota, Shizuoka, JAPAN;  
Akihiro Yamashita, Shizuoka, JAPAN;  
Shuji Tanaka, Shizuoka, JAPAN;

**Power of Attorney:**

Yasuo Muramatsu--38684

**Domestic Priority data as claimed by applicant**

This application is a 371 of PCT/JP2004/018650 12/14/2004

**Foreign Applications**

JAPAN 2004-013487 01/21/2004  
JAPAN 2004-240615 08/20/2004  
JAPAN 2004-240616 08/20/2004

**If Required, Foreign Filing License Granted: 08/09/2008**

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is **US 10/585,707**

**Projected Publication Date: 11/20/2008**

**Non-Publication Request: No**

**Early Publication Request: No**

**Title**

Process of Forming Ultrafine Crystal Layer, Machine Component Having Ultrafine Crystal Layer Formed by the Ultrafine Crystal Layer Forming Process, Process of Producing the Machine Component, Process of Forming Nanocrystal Layer, Machine Component Having Nanocrystal Layer Formed by the Nanocrystal Layer Forming Process, and Process of Producing the Machine Component

**Preliminary Class**

438

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